Notice of Allowability	Application No.	Applicant(s)
	10/648,084	KANDALA, SRINIVAS
	Examiner	Art Unit
	Dargaye H. Churnet	2619
The MAILING DATE of this communication appearance All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this app or other appropriate communication GHTS. This application is subject to	plication. If not included will be mailed in due course. THIS
1. This communication is responsive to <u>26 August 2003</u> .		
2. The allowed claim(s) is/are <u>1-36</u> .		
 3. Acknowledgment is made of a claim for foreign priority unally all black black	been received. been received in Application No	
* Certified copies not received:		
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		complying with the requirements
4. A SUBSTITUTE OATH OR DECLARATION must be submit INFORMAL PATENT APPLICATION (PTO-152) which give		
5. C ORRECTED DRAWINGS (as "replacement sheets") must be submitted.		
(a) ☐ including changes required by the Notice of Draftspers	on's Patent Drawing Review (PTO-	948) attached
1) ☐ hereto or 2) ☐ to Paper No./Mail Date		
(b) ☐ including changes required by the attached Examiner's Paper No./Mail Date	s Amendment / Comment or in the C	rffice action of
Identifying indicia such as the application number (see 37 CFR 1. each sheet. Replacement sheet(s) should be labeled as such in the		
6. DEPOS IT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT I		
Attachment(s) 1. ☑ Notice of References Cited (PTO-892)	5. ☐ Notice of Informal P	atant Application
2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)	6. ☐ Interview Summary	• •
3. Information Disclosure Statements (PTO/SB/08),	Paper No./Mail Dat 7.	e
Paper No./Mail Date4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	8. 🔲 Examiner's Stateme	ent of Reasons for Allowance
5. Diological material	at mrth/IC!	CHAU NGUYEN ORY PATENT EXAMINER OLOGY CENTER 2600